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ABSTRACT

There is disclosed a wet etching agent composition for use in transparent electroconductive films which comprises an aqueous solution containing oxalic acid and a poly(oxyethylene) alkyl ether sulfate and / or a poly(oxyethylene) alkylphenyl ether sulfate. The use of the above etching agent composition enables an amorphous ITO to be etched under mild working conditions, while an etching residue is not generated at all.

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